

Practitioner's D cket No. MI22-1172

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Custer, Dan G.; Ward, Aaron Trent; and Lewis, Shawn M.

Application No.: 09/298,160

Group No.: 1763

Filed: 04/22/1999

Examiner: A. Olsen

For: Polishing Systems, Methods of Polishing Substrates, and Methods of Preparing Liquids for Semiconductor Fabrication Processes

Assistant Commissioner for Patents
Washington, D.C. 20231

AMENDMENT TRANSMITTAL

1. Transmitted herewith is an amendment for this application.

STATUS

2. Applicant is other than a small entity.

EXTENSION OF TERM

3. The proceedings herein are for a patent application and the provisions of 37 C.F.R. 1.136 apply. Applicant believes that no extension of term is required. However, this conditional petition is being made to provide for the possibility that applicant has inadvertently overlooked the need for a petition for extension of time.

CERTIFICATE OF MAILING/TRANSMISSION (37 C.F.R. 1.8(a))

I hereby certify that, on the date shown below, this correspondence is being:


MAILING

- ☐ deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to the Assistant Commissioner for Patents, Washington, D.C. 20231.

Date: 8/10/2000

FACSIMILE

- ☒ transmitted by facsimile to the Patent and Trademark Office.


SignatureCheryl Boies
(type or print name of person certifying)

(Amendment Transmittal—page 1 of 2)